

JRASET!

International Journal for Research in Applied Science & Engineering Technology

IJRASET is indexed with Crossref for DOI-DOI: 10.22214

Website: www.ijraset.com, E-mail: ijraset@gmail.com



It is here by certified that the paper ID: IJRASET22049, entitled

Study of Resistive Switching in Titanium Dioxide (TiO2) Thin Film for the Application of Non-Volatile Memory: A Review

by Tamkeen Farooq

after review is found suitable and has been published in Volume 7, Issue IV, April 2019

in

International Journal for Research in Applied Science & Engineering Technology
(International Peer Reviewed and Refereed Journal)
Good luck for your future endeavors



ISRA Journal Impact Factor: **7.429**









By were

Editor in Chief, iJRASET



JRASET

International Journal for Research in Applied Science & Engineering Technology

IJRASET is indexed with Crossref for DOI-DOI: 10.22214

Website: www.ijraset.com, E-mail: ijraset@gmail.com



It is here by certified that the paper ID: IJRASET22049, entitled

Study of Resistive Switching in Titanium Dioxide (TiO2) Thin Film for the Application of Non-Volatile Memory: A Review

by Sabyasachi Mukaherjee

after review is found suitable and has been published in Volume 7, Issue IV, April 2019

in

International Journal for Research in Applied Science & Engineering Technology
(International Peer Reviewed and Refereed Journal)
Good luck for your future endeavors



ISRA Journal Impact Factor: **7.429**









By were

Editor in Chief, iJRASET